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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/520,042	12/30/2004	Yong Sun	TSUZ 2 00020	9838
27885	7590 04/26/2006		EXAM	INER
FAY, SHARPE, FAGAN, MINNICH & MCKEE, LLP 1100 SUPERIOR AVENUE, SEVENTH FLOOR			FETZNER, TIFFANY A	
	O, OH 44114	FLOOR	ART UNIT	PAPER NUMBER
	•		2859	
			DATE MAILED: 04/26/2000	5

Please find below and/or attached an Office communication concerning this application or proceeding.

			H·A
	Application No.	Applicant(s)	
	10/520,042	SUN ET AL.	,
Office Action Summary	Examiner	Art Unit	
	Tiffany A. Fetzner	2859	
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet w	ith the correspondence addres	ss
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory perions Failure to reply within the set or extended period for reply will, by state that the period for reply will be stated to the period for reply w	DATE OF THIS COMMUNI 1.136(a). In no event, however, may a od will apply and will expire SIX (6) MOI tute, cause the application to become A	CATION. reply be timely filed ITHS from the mailing date of this commu BANDONED (35 U.S.C. § 133).	
Status			
1) ⊠ Responsive to communication(s) filed on 30 2a) □ This action is FINAL. 2b) ⊠ TI 3) □ Since this application is in condition for allow closed in accordance with the practice under	his action is non-final. vance except for formal mat		erits is
Disposition of Claims			
4)	rawn from consideration.		
Application Papers			
9) ☐ The specification is objected to by the Exami 10) ☑ The drawing(s) filed on 12/30/2004 is/are: a Applicant may not request that any objection to the Replacement drawing sheet(s) including the corr 11) ☐ The oath or declaration is objected to by the) accepted or b) ⊠ object he drawing(s) be held in abeya ection is required if the drawing	nce. See 37 CFR 1.85(a). g(s) is objected to. See 37 CFR 1	
Priority under 35 U.S.C. § 119	•		
12) ⊠ Acknowledgment is made of a claim for forei a) ⊠ All b) □ Some * c) □ None of: 1. □ Certified copies of the priority docume 2. □ Certified copies of the priority docume 3. ☒ Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a least open content.	ents have been received. ents have been received in A riority documents have beer eau (PCT Rule 17.2(a)).	Application No I received in this National Sta	ge
。 Attachment(s)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date	Paper No.	Summary (PTO-413) (s)/Mail Date Informal Patent Application (PTO-152 	2)

Art Unit: 2859

DETAILED ACTION

Priority

1. Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.
- 3. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- et al., Japanese article "Dielectric Loss in C₆₀ Films Observed by Direct Coupling with Electromagnetic Fields" Kyushu Institute of Technology March 2002, Vol. 49, No. 2, page 582. (Under the document identifier 29p-YL-17 0226 on page –582-). The examiner notes that this article was published in March of 2002 and applicant's earliest effective priority date, is July 12th 2002. The Son Yu et al., article is also listed as an "X" document on applicant's Japanese international search report, and provides four authors (i.e. Y, Sun, K. Kirimoto, Y. Yamasaki, and T. Miyasato). The instant application has only two inventors: (i.e. Y, Sun, and T. Miyasato). Due to the different inventive entity, the Son Yu et al., Japanese article "Dielectric Loss in C₆₀ Films Observed by Direct Coupling with Electromagnetic Fields" Kyushu Institute of

Application/Control Number: 10/520,042

Art Unit: 2859

Technology March 2002, Vol. 49, No. 2, page 582 is available as prior art against the claims of the instant application under 35 U.S.C. 102(a).

- 5. The examiner also notes that the rejections below are based off of an "unofficial" oral / machine translation of the Japanese article.
- With respect to Claim 1, the Son Yu et al., Japanese article teaches, "A method 6. for measuring the molecular rotation" (i.e. molecular rotational frequency) [See the experimental results section on page 582] as well as the shift / change / increase in rotational frequency (i.e. "speed") "of a fullerene or a fullerene derivative" [See C60] "which comprises having a thin film of the fullerene or the fullerene derivative absorb an electromagnetic wave varied in frequency" [See the methods and experimental results section where a thin film of C60 absorbs / attenuates a radio wave with a variable frequency range of 50Mhz to 500Mhz , using a LiNbO₃ crystal. Additionally, the **Son Yu** et al., Japanese article teaches, "measuring the change in electromagnetic wave intensity against temperature, thereby determining the molecular rotation speed of the fullerene or the fullerene derivative from the frequency of the electromagnetic wave at a temperature where there is an abrupt change in the electromagnetic wave intensity from the absorption region to the non-absorption region". [See the methods and experimental results section where the change in intensity from the absorption region to the nonabsorption region against temperature for 15K-300K, is determined and calculations are performed with respect to 50K, 165K, and 220K specifically, which results in the rotational frequency being determined along with the change in rotational frequency. (i.e. a change in rotational frequency imparts an increase or decrease in rotational frequency 'speed" with respect to the abrupt temperature change of 50K, to 165K, and to 220K)].
- 7. With respect to Claim 2, the Son Yu et al., Japanese article teaches, that "the electromagnetic waves produced from the surface of a surface acoustic wave (i.e. SAW) "device are used". [See the method / middle paragraph where an SAW device is directly disclosed.] The same reasons for rejection, that apply to claim 1 also apply to claim 2 and need not be reiterated.

Art Unit: 2859

Conclusion

- 8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tiffany Fetzner whose telephone number is: (571) 272-2241. The examiner can normally be reached on Monday-Thursday from 7:00am to 4:30pm., and on alternate Friday's from 7:00am to 3:30pm.
- 9. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Diego Gutierrez, can be reached at (571) 272-2245. The **only official fax phone number** for the organization where this application or proceeding is assigned is (571) 273-8300.
- 10. Information regarding the status of an application may be obtained from the Patent Application information Retrieval (PAIR) system Status information for published applications may be obtained from either Private PMR or Public PMR. Status information for unpublished applications is available through Private PMR only. For more information about the PMR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PMR system contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

April 24, 2006

Diego Gutierrez Supervisory Patent Examiner Technology Center 2800